

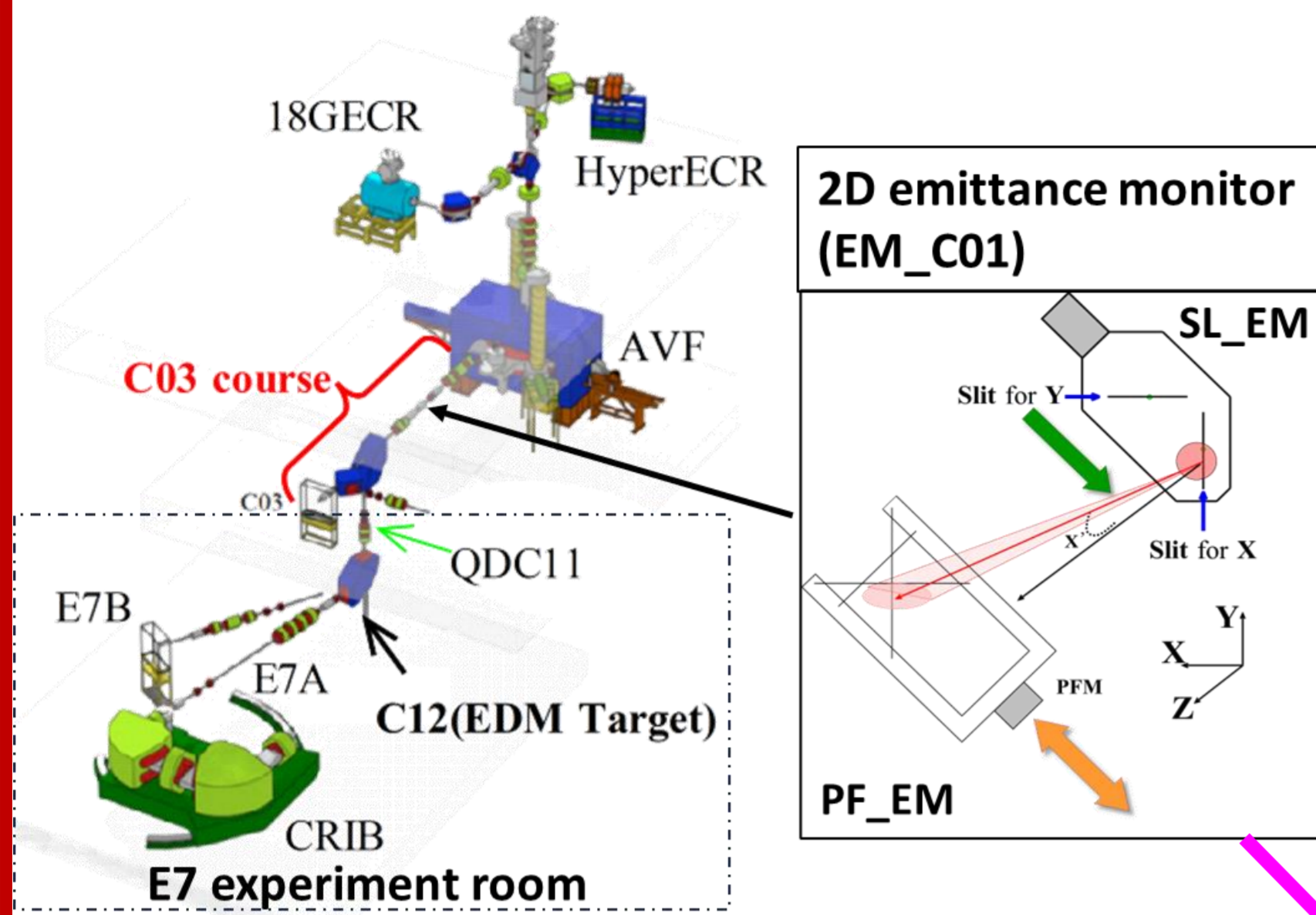
HIGH-INTENSITY ION BEAM ACCELERATED BY RIKEN AVF CYCLOTRON

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At the Center for Nuclear Study of the University of Tokyo (CNS), the measurement of Electric Dipole Moment (EDM) of Francium (Fr) is underway with the world highest precision. Fr is generated by nuclear fusion reaction by irradiating the gold (Au) target of EDM experiment device (EDM target) with oxygen ion beam $18O^{6+}$ of 7 MeV/u accelerated by RIKEN AVF Cyclotron.

Our goal is transporting beam of more than 18 μA (400 W), without loss and converging beam to be 1 mm of SD of beam distribution on the EDM target.

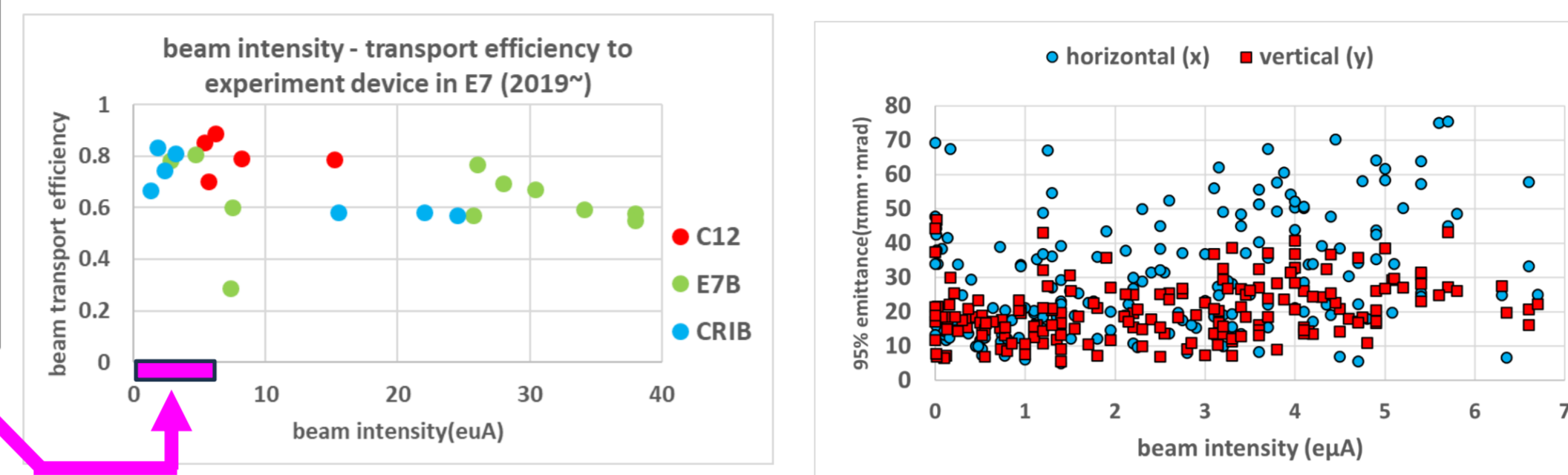
AVF Cyclotron and beam transport system to C12, CRIB, and E7B



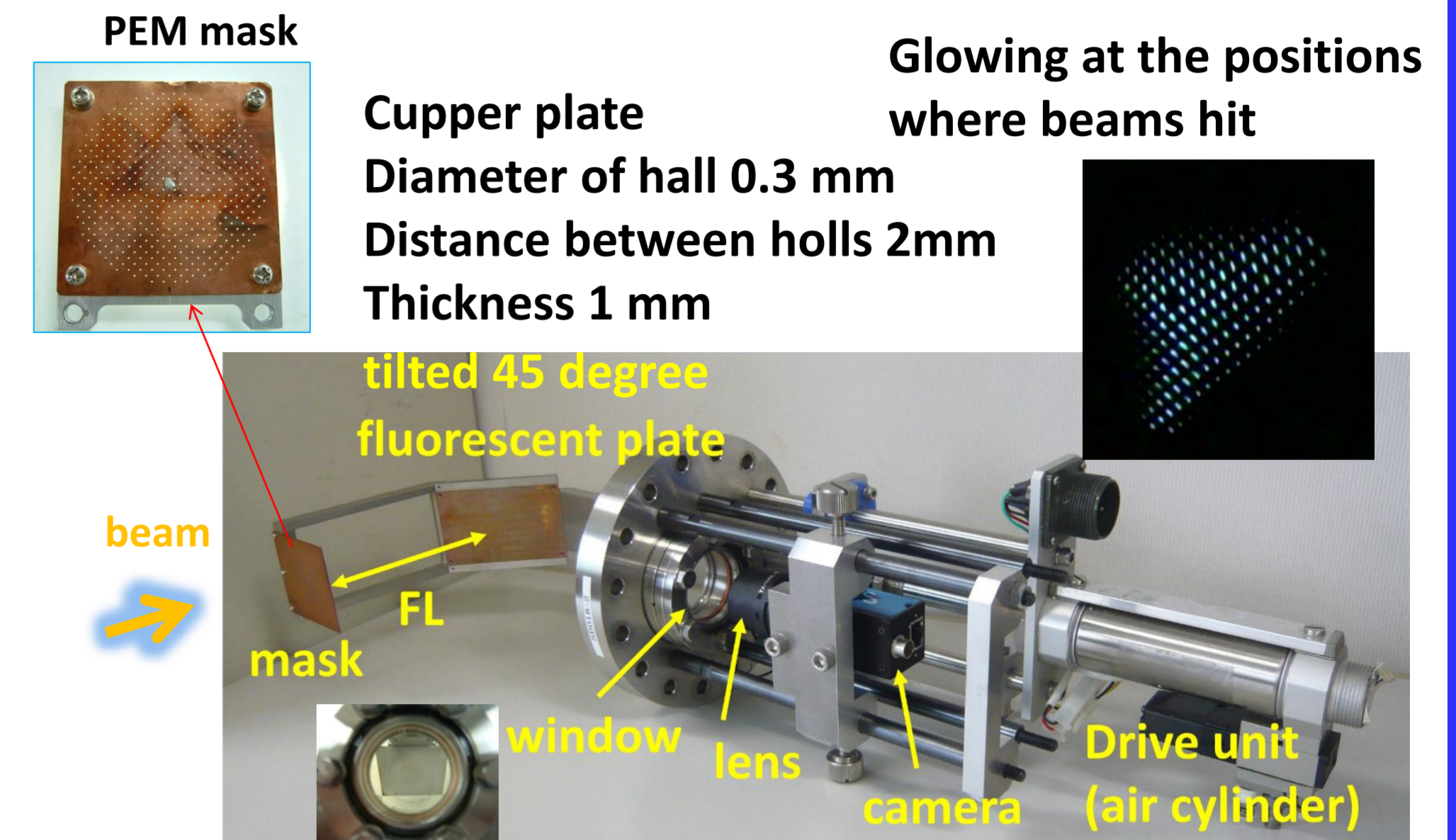
Our problem

Beam transport efficiency is average 66 %
 When beam intensity > 10 μA

Beam emittance expands as intensity increase



Pepper-pot emittance monitor



Old emittance monitor (EM_C01) cannot measure High intensity beam because Cooling Ability < 130 W beam. has unsolved measurement error.

Developing Pepper-pot emittance monitor for high intensity beam

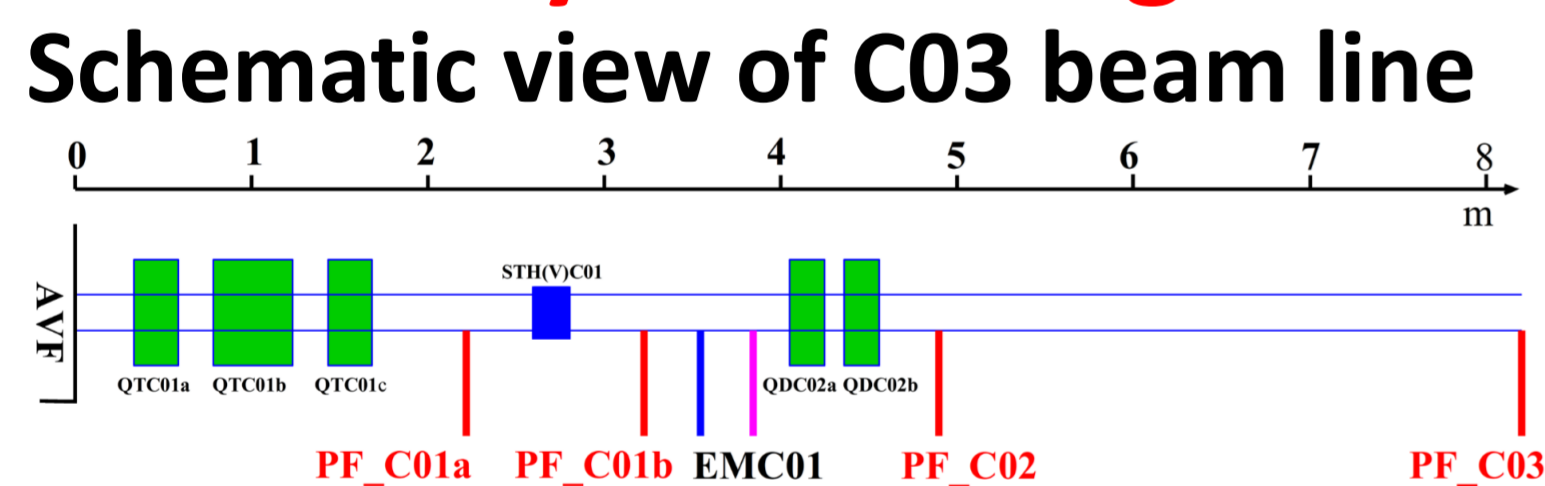
We need more three additional development.

- ① reducing the radiation damage to a camera
- ② required angular accuracy for the accelerated beam
- ③ beam shutter system to avoid heating PEM due to beam

① reducing the radiation damage to a camera - tele lens optics of camera Achieving 2200 mm between Camera and PEM by now

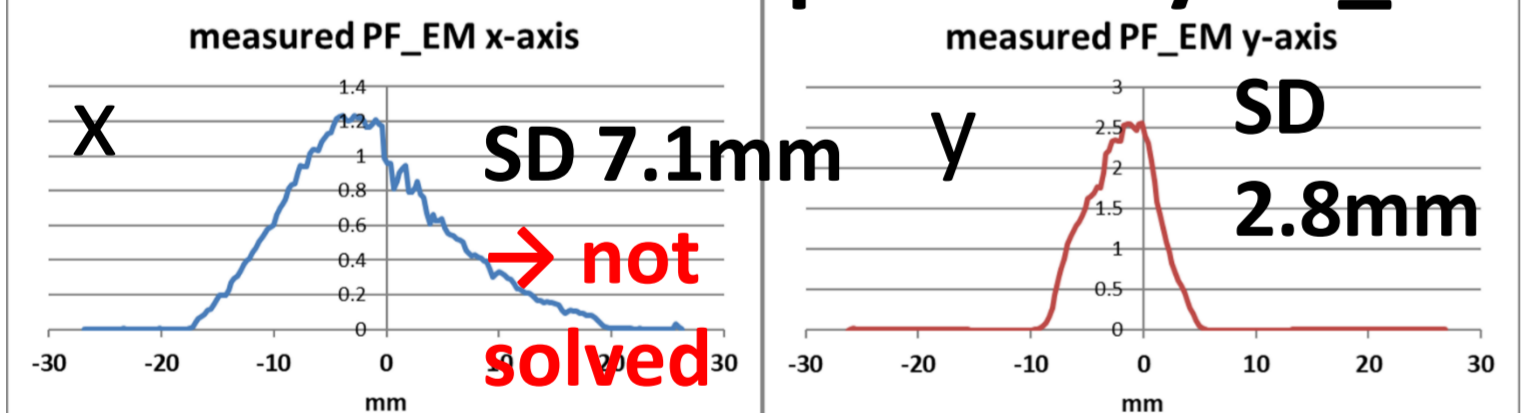
② required angular accuracy for the accelerated beam

The way estimating σ matrix assumed to be true

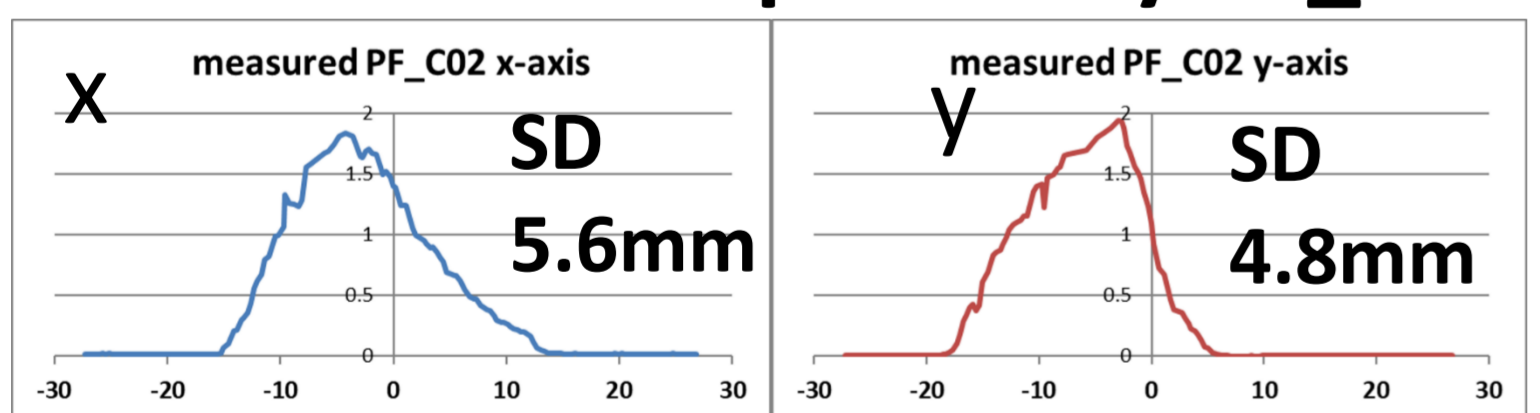


$^{19}F^{7+}$ 6.68MeV/u 5 μA

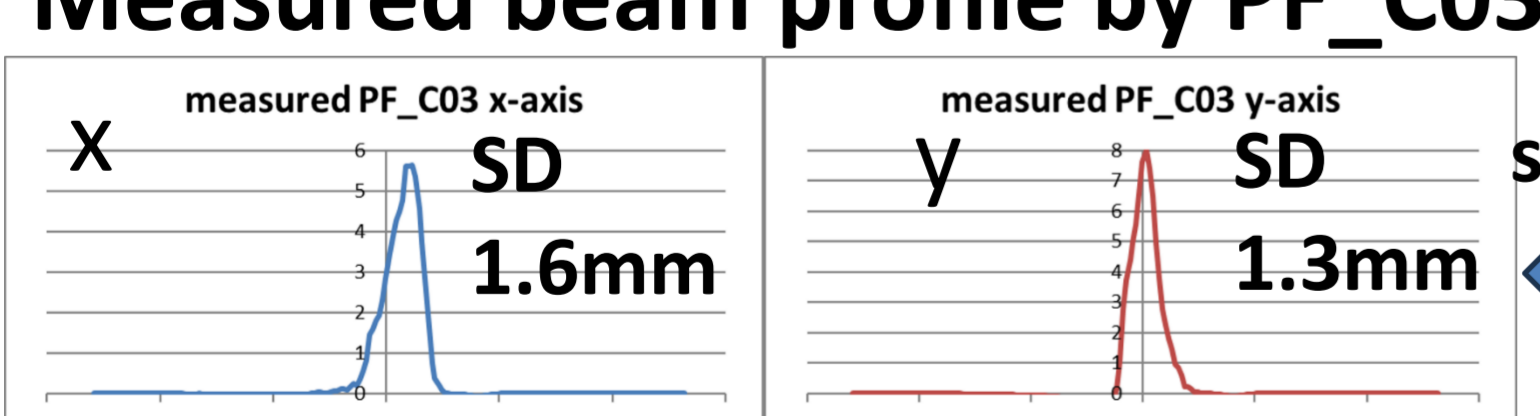
Measured beam profile by PF_EM



Measured beam profile by PF_C02



Measured beam profile by PF_C03



Equation of σ matrix. σ_{11} known

$$\begin{pmatrix} \sigma_{11}(C02) \\ \sigma_{21}(C02) \\ \sigma_{22}(C02) \end{pmatrix} = \begin{pmatrix} m_{11} & m_{12} & m_{13} \\ m_{21} & m_{22} & m_{23} \\ m_{31} & m_{32} & m_{33} \end{pmatrix} \begin{pmatrix} \sigma_{11}(EM) \\ \sigma_{21}(EM) \\ \sigma_{22}(EM) \end{pmatrix}$$

$$\begin{pmatrix} \sigma_{11}(C03) \\ \sigma_{21}(C03) \\ \sigma_{22}(C03) \end{pmatrix} = \begin{pmatrix} 1 & 2L & L^2 \\ 0 & 1 & L \\ 0 & 0 & 1 \end{pmatrix} \begin{pmatrix} \sigma_{11}(C02) \\ \sigma_{21}(C02) \\ \sigma_{22}(C02) \end{pmatrix}$$

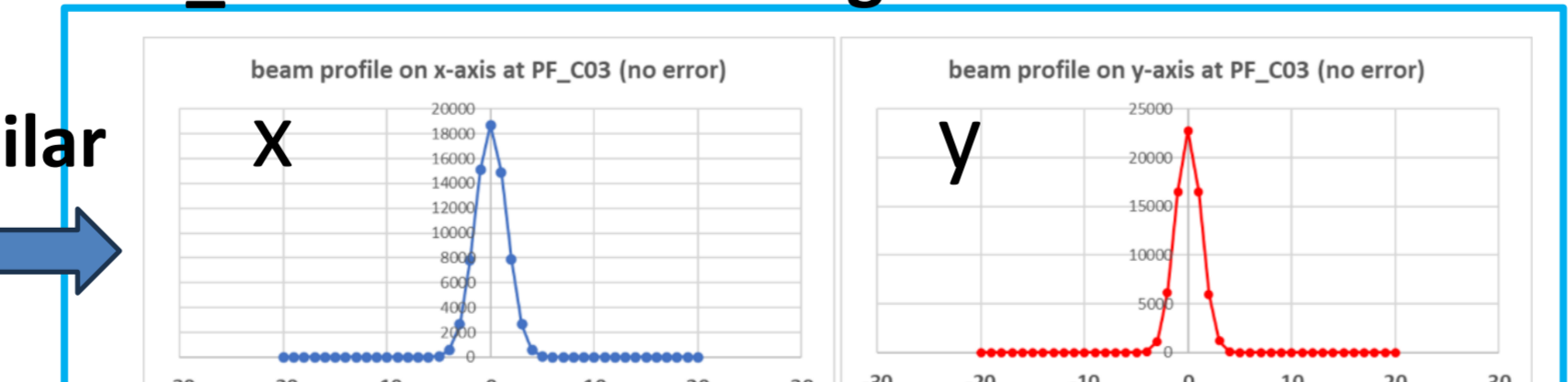
Solution of equation (SDx of PF_EM 8 mm)

	σ_{11}	σ_{21}	σ_{22}	σ_{33}	σ_{43}	σ_{44}
PF_EM	64.0	67.46	71.20	7.84	1.47	0.56
PF_C02	31.36	-8.45	2.48	23.04	-5.87	1.59
PF_C03	2.56	-0.33	2.48	1.69	-0.65	1.59

σ matrix assumed to be true

$$\begin{pmatrix} \sigma_{11} & \sigma_{12} & \sigma_{13} & \sigma_{14} \\ \sigma_{21} & \sigma_{22} & \sigma_{23} & \sigma_{24} \\ \sigma_{31} & \sigma_{32} & \sigma_{33} & \sigma_{34} \\ \sigma_{41} & \sigma_{42} & \sigma_{43} & \sigma_{44} \end{pmatrix} = \begin{pmatrix} 28.1 & 44.6 & 0 & 0 \\ 44.6 & 72.0 & 0 & 0 \\ 0 & 0 & 7.0 & 1.3 \\ 0 & 0 & 1.3 & 0.6 \end{pmatrix} \text{ At EM_C01}$$

PF_C02 calculated using above σ matrix



estimate the beam size including error at the EDM target due to the EM_C01 measurement error.

random numbers following 4-variables normal distribution
 Calculated phase space at z=0

Error simulation

- 1: adding random numbers following normal distribution having SD as error
- 2: Recomputing angle

The relationship between angular error of EM_C01 and calculated beam size (SD) at EDM Target

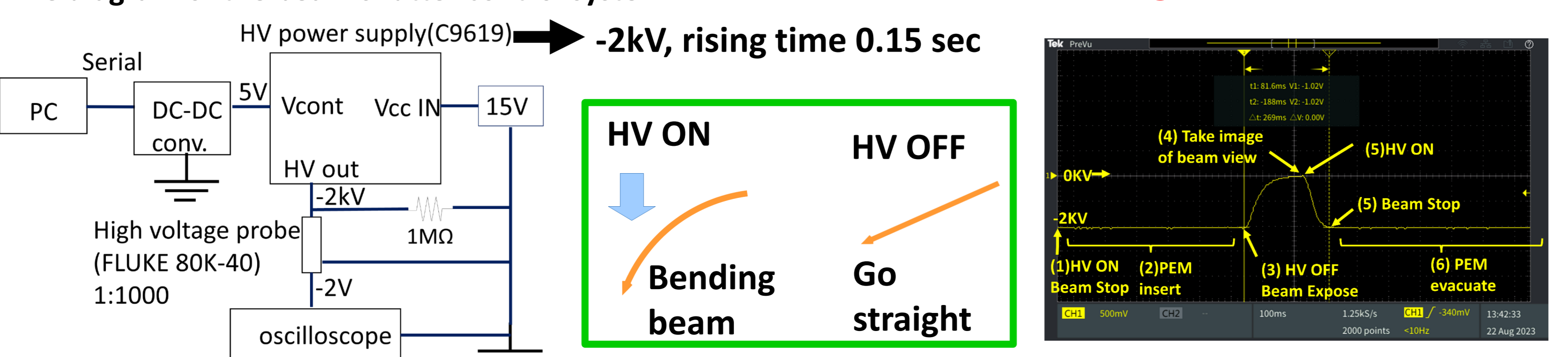
Required less than 0.3 mrad of angular accuracy of PEM

③ Beam shutter system to avoid heating PEM from beam

No cooling — to shorten the measurement time

The beam stops by applying a high voltage to the electrode set in the beam line just behind an ion source and bending the beam sideways.

The diagram of the beam shutter control system



Dividing the measurement errors of PEM from the emittance assumed to be true by error simulation.

Our requirement for facility of beam test

- low beam emittance,
- no correlation between x and y,
- three BPMs in a beam line,

Micro Analysis Laboratory, Tandem accelerator (MALT), The University of Tokyo. The PEM installation with tele lens camera optics was complete. This beamline has two BPMs at 735 mm upstream and 2070 mm downstream from the PEM. Moreover, since the PEM becomes BPM with the average position error of 0.15 mm, we have three BPMs.